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## Silicon Photonics XX

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## Contents

vii Conference Committee

	WAVEGUIDE DEVICES AND APPLICATIONS I
13371 02	Silicon photonic Bragg grating filter developed in a generic foundry process [13371-2]
13371 03	Mid-infrared frequency comb generation for sensing applications (Invited Paper) [13371-3]
13371 04	High throughput testing of Si photonics components using OFDR [13371-4]
	ACTIVE INTEGRATION I
13371 05	Widely tunable external cavity lasers based on the 3µm-thick silicon-on-insulator platform for operation in the C and L bands in the DYNAMOS EU project [13371-6]
13371 06	Reliability of III-V/Si heterogeneously integrated lasers [13371-7]
13371 07	Photonics for space: radiation testing of silicon photonic modulator via International Space Station flight [13371-8]
	WAVEGUIDE DEVICES AND APPLICATIONS II
13371 09	Metamaterial-engineered fiber-chip couplers in silicon and silicon nitride waveguides (Invited Paper) [13371-14]
13371 0A	Enhanced silicon photonic switch fabrics with variation-aware optimized Mach-Zehnder interferometers [13371-15]
13371 OB	Phase behaviors of several types of MMI couplers and their application to flatband CWDM demultiplexers [13371-17]
13371 OC	High efficiency silicon photonics grating coupler compatible to standard foundry service [13371-18]
	QUANTUM AND NONLINEAR PHOTONICS
13371 0D	Visible-wavelength quantum photonics in a 4H silicon carbide platform [13371-22]

## INTEGRATED DETECTORS AND SENSORS

13371 OE	Development of high-performance short-wave infrared Ge-on-Si linear mode avalanche photodiodes [13371-24]	
13371 OF	UV to NIR detection with p*n-type PureB Ge-on-Si photodiodes fabricated on lightly doped n-Si substrates $[13371\text{-}25]$	
13371 0G	Leveraging a SiPh Mid-IR platform for integrated thermal source and detector to measure CO2 and CH4 levels, AEOLUS [13371-26]	
	ACTIVE INTEGRATION II	
13371 OH	Heterogeneous integration of O-band GaAs QD-on-SiN Fabry-Pérot laser with observed mode-locking [13371-28]	
	ACTIVE INTEGRATION III	
13371 01	A 50Gb/s optical PAM4 transceiver heterogeneously integrated with microring modulator and avalanche photodiode [13371-31]	
13371 OJ	A 5-µm radius compact ring modulator with a wide free spectral range, large extinction ratio, and high wavelength modulation developed in AIM Photonics' 300 mm process technology [13371-32]	
13371 OK	Microtransfer printing of InP SOAs on advanced silicon photonics platform for C-band preamplified receivers [13371-33]	
	POSTER SESSION	
13371 OL	Study of microring nonlinearities in silicon photonics for neuromorphic computing [13371-36]	
13371 ON	Demonstration of a tunable add-drop filter developed in AIM Photonics process technology [13371-38]	
13371 00	The application of silicon-based Schottky infrared photodetectors in gas detection [13371-39]	
13371 OP	Modelling of a narrow linewidth monolithically integrated quantum dot-on-silicon extended cavity laser [13371-40]	

13371	W-shaped PN junction for high efficiency and fast op	tical phase shifters [13371-47]
1337	Toggleable transparency states in thermally-shifted n	nultiMRR cascaded filters [13371-48]
13371	On demand control of the strain state in Ge-GeSn microbridges [13371-49]	
	DIGITAL POSTER SESSION	
13371	Slow-light lasing in 1D photonic crystal InGaAs/GaAs wafer [13371-30]	nano-ridges epitaxially grown on a S